# Solar-Cell Interconnect Design for Terrestrial Photovoltaic Modules

G. R. Mon

D. M. Moore

R. G. Ross, Jr.

Jet Propulsion Laboratory, California Institute of Technology, 4800 Oak Grove Drive, Pasadena, Calif. 91109

An investigation of interconnect fatigue in photovoltaic systems has led to the development of useful reliability-design and life-prediction algorithms presented here. Experimental data gathered in this study indicate that the classical strain-cycle (fatigue) curve for the interconnect material fails to account for the broad statistical scatter, which is critical to reliability prediction. To fill this shortcoming, a functional form is fitted to experimental cumulative interconnect failure-rate data to yield statistical fatigue curves (with failure probability as a parameter) that enable (a) the prediction of cumulative interconnect failures during the design life of an array field, and (b) the unambiguous—i.e., quantitative—interpretation of data from field-service qualification (accelerated thermal-cycling) tests. Optimal interconnect cost-reliability design algorithms are derived, intended to minimize the cost of energy over the design life of the array field. This procedure yields not only the minimum break-even cost of delivered energy, but also the required degree of interconnect redundancy and an estimate of array power degradation during the design life of the array field. The usefulness of the design algorithms is demonstrated with realistic examples of design optimization, prediction, and service qualification testing.

## Introduction

Comprehensive investigations of failure modes affecting photovoltaic module performance and reliability are a major effort of the Engineering Sciences Area of the Jet Propulsion Laboratory's Flat-Plate Solar Array Project. The objective of this research is to define means of reducing the cost and improving the utilty and reliability of photovoltaic modules for the broad spectrum of terrestrial applications. It is in this light that this paper addresses the interconect failure problem.

Interconnect failure is induced by diurnal thermal cycles, which cause the distance between adjacent cells to expand and contract, thereby straining the interconnect(s) joining them. After a number of such cycles, depending on the strain levels induced in each interconnect, microcracks develop and eventually propagate across the width of the interconnect until separation (open circuit) occurs. Thus the underlying failure mechanism is mechanical fatigue.

Metallurgists characterize fatigue by means of empirical strain-cycle (fatigue) curves that define the mean number of cycles to failure versus the strain level in the subject material. However, the life of any individual interconnect is governed by its flaw strength as determined by such agents as metallurgical defects and manufacturing variations in shaping and attachment. The results is that each interconnect fails randomly, yet the fraction of equally strained interconnects that fail in an arbitrarily chosen time interval is statistically predictable.

When every parallel interconnect connecting an adjacent

cell pair has failed, the substring containing that cell pair can no longer deliver its energy to the load; the result of interconnect failures is thus degradation of array power output. The use of redundancy in the deployment of interconnects can decrease the rate of degradation and, in fact, a sufficiently high degree of redundancy can reduce the degradation to negligible levels. Excessive interconnect redundancy, however, is costly. Economic considerations dictate a tradeoff between the degree of redundancy (cost) and the rate of power reduction (performance). This tradeoff is achieved by minimizing the cost of energy generated over the life of the array.

Module-interconnect reliability design and life-prediction procedures are presented herein that enable the module manufacturer to:

- 1 calculate interconnect strain levels for a particular module-interconnect design configuration;
- 2 predict the cumulative interconnect failure fraction at end-of-array-life, assuming interconnect fatigue to be the only active failure mechanisms;
  - 3 estimate array power degradation;
- 4 determine the degree of interconnect redundancy necessary to achieve minimum life-cycle cost of energy over the intended life of the array; and
- 5 establish the maximum allowable fraction of interconnect failures, and hence a nonarbitrary pass-fail threshold, in an accelerated thermal-cycling test.

## Module Interconnect Design Procedure

Interconnect analysis and design for photovoltaic arrays,

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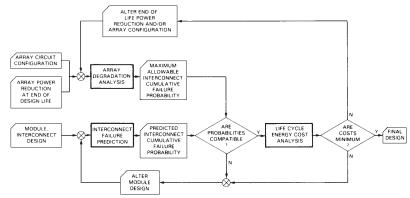


Fig. 1 Module interconnect design procedure

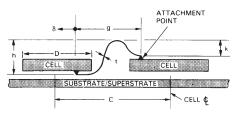


Fig. 2 Module interconnect geometry

particularly for space applications, are well documented [1]. It is known that good interconnect design practice requires:

- 1 minimizing the thickness,
- 2 maximizing the expansion loop height;
- 3 maximizing the length, i.e., the distance between interconnect-to-cell attachment points; and
- 4 avoiding solder and/or adhesive overflow onto the interconnect, which effectively shortens its active length, thereby overstraining the interconnect material.

Each of these techniques reduces the effective strain range (i.e., the maximum peak-to-peak strain in the interconnect material, hereinafter called the strain), thereby prolonging interconnect life.

An effective process of module-interconnect design involves comparing the predicted end-of-design-life cumulative interconnect failure probability, calculated for a definite module-interconnect design and site-specific temperature and insolation history, with a table of maximum allowable interconnect failure probabilities determined from considerations of end-of-life array power reduction and circuit and interconnect redundancy, for which minimum life-cycle energy costs have been determined. In addition to minimum cost, this comparison yields the required interconnect redundancy and provides an estimate of the end-of-life array power reduction. The design procedure is presented in Fig. 1.

In the following three sections the analytical procedures represented by the rectangles in Fig. 1 will be presented, with examples, in summary form. The reader desiring detailed exposition is referred to a report [2] which treats this subject comprehensively.

#### **Interconnect Failure Prediction**

This section outlines a procedure for computing cumulative interconnect failure probability at end-of-life starting with a specific module-interconnect design concept and deployment site temperature history. Steps include computing interconnect displacement, computing interconnect material strain, and computing interconnect failure probability.

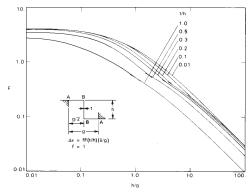


Fig. 3 Shape factor F for Z-type interconnect

Computing Interconnect Displacement. The first step is to determine the effective thermally induced change  $\delta$  in the distance g between points where the interconnect is attached to adjacent cells (Fig. 2). This effective thermal displacement  $\delta$  is determined from module design, geometry, and material properties, and site-dependent average diurnal temperature variations. The total diurnal temperature change may be taken as

$$\Delta T = \Delta T_D + \Delta T_{op} \tag{1}$$

where

 $\Delta T_D$  = difference between daily high and low ambient temperatures

 $\Delta T_{op}$  = module operating temperature above ambient (about 30°C for most module designs at 100 mW/cm<sup>2</sup> irradiation)

The effective interconnect displacement is given by

$$\delta = \left[ (\alpha_s - \alpha_c) C + (\alpha_c - \alpha_I) g \right] \Delta T \tag{2}$$

where

 $\delta$  = effective change in the distance between attachment points

C = center-to-center distance between cells

D =solar cell diameter

g = distance between attachment points of the interconnects

 $\alpha_s$  = thermal expansion coefficient of the substrate or superstrate

 $\alpha_c$  = thermal expansion coefficient of the solar cells

 $\alpha_I$  = thermal expansion coefficient of the interconnect material

 $\Delta T$  = diurnal temperature variation

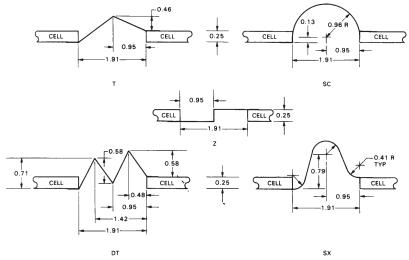


Fig. 4 Geometry of interconnects mechanically cycled to failure and their code designations (all dimensions are in millimeters)

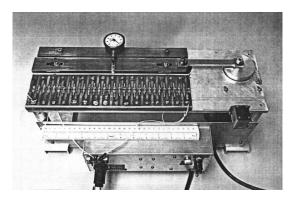


Fig. 5 Interconnect strain-cycle (fatigue) apparatus

Computing Interconnect Material Strain. Having determined the interconnect displacement from temperature variations, the next step is to calculate the total strain range  $\Delta\epsilon$  induced in the interconnect material by the displacement  $\delta$ . For complex interconnect configurations this step requires computer assistance using finite element modeling techniques of structural analysis. To circumvent the time and cost inherent in computer use, nomographs have been developed in this study (a representative nomograph is presented in Fig. 3) to permit rapid graphical determination of strain levels in several important interconnect configurations, including the T-, SC-, and Z-interconnect configurations of Fig. 4 [2].

The maximum strain in the interconnect can be expressed as

$$\Delta \epsilon = F \cdot \left(\frac{t}{h}\right) \cdot \frac{\delta}{g} \tag{3}$$

where

 $\Delta \epsilon = \text{maximum strain in the interconnect}$ 

t =thickness of interconnect

h =height of interconnect

 $\delta$  = effective change in attachment-point-to-attachment-point dimension

g = attachment-point-to-attachment-point dimension

F = shape factor computed using the nomograph, Fig. 3

Computing Interconnect Failure Probability. Having determined maximum interconnect strain from displacement  $\delta$ , the final step is to calculate the predicted fraction  $p_I$  of interconnects (the interconnect failure probability) that will

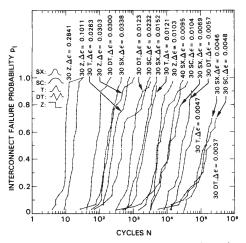


Fig. 6 Experiment failure probability versus number of cycles to failure for 0.051-mm-thick OFHC interconnect configurations

fail in a specified number of cycles. This is achieved through the use of statistical fatigue curves, a set of standard straincycle curves parameterized by the interconnect cumulative failure probability. Statistical fatigue curves have been generated for several materials of interest by fitting suitable functions to the experimental cumulative interconnect failurerate data [3].

Experimental Failure-Rate Data. To achieve further understanding of interconnect fatigue statistics, a large number of interconnects were fabricated and tested to failure in this study. Test specimens are 0.051-mm-thick OFHC 1/4hard copper interconnects shaped by precisely machined dies to the configurations shown in Fig. 4. In each test 30 specimens of the same configuration are carefully mounted on the test fixture shown in Fig. 5. This device consists of two horizontal plates vertically offset 0.254 mm to simulate the thickness of a typical solar cell and horizontally separated by a nominal 1.905-mm gap to simulate a typical cell-to-cell gap in a module. One plate is then made to move horizontally back and forth relative to the other at a constant (but adjustable) cycle rate and amplitude. The interconnects are series-wired so that, when a break occurs, the cycling ceases. The number of cycles to failure of each interconnect is recorded and testing continues until the next failure or the end of the test.

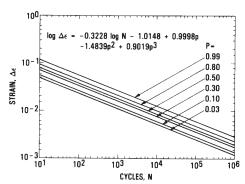


Fig. 7 Statistical fatigue curve for OFHC copper

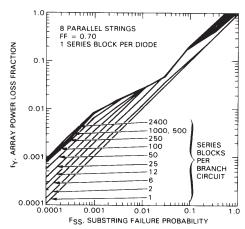


Fig. 8 Array power loss

The raw data obtained from this testing procedure are presented in Fig. 6 as a plot of cumulative interconnect-failure probability versus the number of cycles to failure. The data curves are labeled with the number of interconnects of the particular configuration tested and with the strain range  $\Delta\epsilon$  calculated using a finite-element program or the nomographs developed in this study [2].

**Statistical Fatigue Curves.** The functional relationship between strain range, strain cycles, and probability of failure is given by

$$\Delta \epsilon = K \cdot f(p) \cdot N^b \tag{4}$$

where

 $\Delta \epsilon = \text{interconnect strain range}$ 

N = number of imposed strain cycles

f(p) = a function that describes the parametric dependency of  $\Delta \epsilon$  and N on the probability of interconnect failure

K,b =intercept and slope constants.

The function f(p) is chosen as

$$f(p) = 10^{\frac{3}{\sum_{i=0}^{3} a_i p^i}}$$
 (5)

i.e., an exponential cubic polynomial. For OFHC 1/4-hard copper, the curve-fitting procedure [3] yields the statistical fatigue curves presented in Fig. 7.

Figure 7 can now be used to complete the interconnect failure prediction calculation. Having previously computed the interconnect strain range  $\Delta\epsilon$ , one enters the graph in Fig. 7 with this strain value on the ordinate, and with the number of cycles N corresponding to the number of days in the design life on the abscissa. Where these two coordinate lines intersect

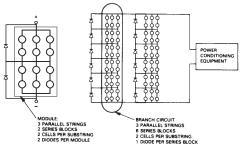


Fig. 9 Series-parallel nomenclature

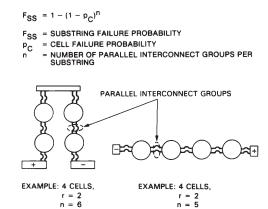


Fig. 10 Relation between substring and cell failure probabilities

determines the predicted failure probability. Interpolation is usually required.

An Example. Consider as an example a module-interconnect design representative of present module construction, viz, a glass-superstrate module with Z-type interconnects. The design parameters are:  $\alpha_s = 9.2 \times 10^{-6}$  cm/cm°C (glass),  $\alpha_c = 2.9 \times 10^{-6}$  cm/cm/°C (silicon),  $\alpha_l = 17 \times 10^{-6}$  cm/cm/°C (copper), C = 10.16 cm, D = 9.96 cm,

## **Array Degradation Analysis**

The module interconnect design procedure presented in Fig. 1 enables the designer of photovoltaic modules to determine the degree of interconnect redundancy required to achieve minimum cost and acceptable end-of-design-life array power reductions. The interconnect failure prediction algorithm presented in the previous section provides a means of predicting the fraction of failed interconnects at end-of-life for a particular module interconnect design.

In this section a companion algorithm is presented that generates the interconnect failure fraction  $p_I$  associated with a specified end-of-life array power-loss fraction  $f_Y$  and degree of interconnect redundancy r. The designer can compare his predicted failure fractions with a table of failure probabilities generated from considerations of array power degradation to determine the degree of interconnect redundancy that will result in acceptable array power reductions.

The dependence of array power degradation on circuit redundancy (series-paralleling) has been illuminated by Ross [4]. Figure 8 illustrates this dependency for a limited range of

array series-parallel-diode configurations. A voluminous parametric analysis [5, 6] has yielded many such curves, which (with additional array circuit design considerations) are collected in [7]. The reader who is unfamiliar with seriesparallel nomenclature should refer to Fig. 9 for assistance.

The substring and interconnect failure probabilities are numerically related as follows:

$$p_{c} = p_{I}^{r} \tag{6}$$

and

$$F_{ss} = 1 - (1 - p_c)^n \tag{7}$$

where

 $F_{ss}$  = substring failure probability

n = number of parallel interconnect groups per substring (see Fig. 10)

pc = cell failure probability

r = degree of interconnect redundancy

 $p_I$  = interconnect failure probability

The array power-loss fraction is assumed to result from substring failures caused by interconnect failures only.

An Example. To demonstrate the use of the array degradation algorithm, consider the example array design presented in Table 1.

The array degradation will be determined for a 20-year cumulative interconnect failure fraction  $p_I = 0.054$  and an interconnect redundancy r = 3. Using these figures in equation (6) gives a cumulative cell failure probability  $p_c$  =  $1.58 \times 10^{-4}$ . Then equation (7) with n = 12 (see Fig. 10) gives a substring failure probability  $F_{ss} = 0.00189$ . Entering Fig. 8 with this value as abscissa and using the curve corresponding to 57 series blocks per branch circuit (interpolation required), it is determined that the array power loss fraction at 20 years is  $f_Y = 0.0088$  (power down 0.88

In this fashion an entire table (Table 2) of power reductions associated with specific failure probabilities and interconnect redundancies has been generated. The strain values listed in Table 2 were determined from the probabilities using the equation given in Fig. 7 with N = 7300 cycles (20 years).

#### Table 1 Example design parameters

Array configuration

- (1) OFHC copper interconnects.
- (2) 8 parallel by 11 series cells per series block: n = 12.
- (3) 57 series blocks per branch circuit.
- (4) 1 series block per diode. (5)  $V_{\text{array}} = 250 \text{ V}.$

Design objectives

- (1) 20-year array power reduction.
- (2) Interconnect failure probility.
- (3) Minimum life-cycle energy cost.
- (4) Required interconnect redundancy.

Table 2 suggests two generalizations: (a) adding interconnects, i.e., increasing redundancy, dramatically reduces the array power loss rate over the 20-year array life; and (b) allowing a higher maixmum strain results in considerably larger power loss rates. These observations are not surprising, but the large sensitivity of array power loss to variations in strain is.

## **Life-Cycle Energy Cost Analysis**

As was indicated in the previous section, the end result of interconnect failures is degradation of array power output. It was also shown that design techniques such as redundant interconnects can decrease the rate of degradation to negligible levels. Excessive interconnect redundancy, however, is costly. Economic considerations dictate a tradeoff between the degree of redundancy (cost) and the rate of power reduction (performance). This tradeoff is described in this section; it is achieved by minimizing the cost of energy generated over the life of the array.

The cost of energy over the lifetime of the array field is determined by equating the worth of delivered energy to the cost of obtaining that energy. Letting R represent the (constant) cost of energy, it follows [2, 4, 8] that

$$R = \frac{C_B + \frac{C_A + C_I + C_M}{\eta}}{I_0 \epsilon_{LC}} \tag{8}$$

where

R = constant worth of energy over array lifetime, \$/kWh $C_B$  = balance of plant costs, \$/kW

 $C_A$  = initial array costs less redundant interconnects,  $m^2$ 

 $C_I$  = estimated add-on cost of interconnects per square meter of module area, \$/m<sup>2</sup>

 $C_M$  = life-cycle operation and maintenance costs, \$/m<sup>2</sup>

 $\eta = \text{plant efficiency } (100 \text{ mW/cm}^2, \text{ NOCT})$ 

 $I_0$  = annul solar insolation, kWh/m<sup>2</sup>/year

 $\epsilon_{LC}$  = life-cycle energy fraction

The life-cycle energy fraction  $\epsilon_{LC}$  is the present value of energy output over the life of the array; for zero discount rate, it is determined as the area under the curve of power output fraction  $1 - f_{\nu}$  versus array operation time [2].

Equation (8) provides the basis for conducting the economic tradeoff between interconnect fatigue life, interconnect redundancy, array degradation, and the fabrication costs associated with the various interconnect options.

An Example. To illustrate the application of equation (8), consider again the example design problem defined in Table 1. The assumed system cost and performance parameters that are independent of the interconnect design are presented in

Table 2 Array power reduction at 20 years

20-Year <i>p<sub>I</sub></i>	Maximum allowable strain —	Array power reduction at 20 years $f_y$						
		r=1	2	3	4	5	6	
0.005	0.0055	0.125	0.0018	0	0	0	0	
0.010	0.0056	0.240	0.0059	0	0	0	0	
0.050	0.0061	0.71	0.05	0.0070	0.0004	0	0	
0.100	0.0067	0.96	0.24	0.029	0.0005	0.0007	0	
0.150	0.0072	1.00	0.31	0.054	0.019	0.005	0.0013	
0.200	0.0077	1.00	0.57	0.19	0.038	0.013	0.003	
0.300	0.0085	1.00	0.90	0.46	0.20	0.048	0.023	
0.400	0.0091	1.00	1.00	0.90	0.45	10.26	0.085	
0.500	0.0096	1.00	1.00	1.00	0.80	0.53	0.32	

Table 3. Assumed add-on costs for just the interconnects are presented in Table 4 as a function of interconnect redundancy. The objective of the analysis is to determine the appropriate choice of interconnect redundancy in light of the costs, array degradations, and interconnect failure probabilities.

The results of the analysis [2], are displayed in Table 5. It is evident from Table 5 that life-cycle costs increase with increasing failure probability. Minimum costs for a given maximum allowable failure probability are boxed. It is noted that cost optimization requires that modules be designed for operation at low strain levels, although the variation in costs over the two-orders-of-magnitude range of interconnect failure probabilities is small. It is also noted that the various cost minima are relatively flat; e.g., at  $p_I = 0.05$ , the cost

Table 3 Design example cost parameters

Balance of plant costs Initial array costs less	$C_B = 250  \text{kW}$
redundant interconnects	$C_A = 113  \text{/m}^2$
Operation and maintenance costs Total plant efficiency	$C_M = 0$ $\eta = 0.092$
Annual insolation	$I_0 = 2000  \text{kWh/m}^2/\text{yr}$

Table 4 Add-on costs for interconnects

Interconnect redundancy	Estimated costs for interconnects $C_I$ \$/m <sup>2</sup> of module surface
2	4.22
3	5.05
4	6.18
5	7.75
6	9.99

difference in using three, four, or five interconnects is negligible. This is surprising, considering the extremely large variation in array power reduction for these degrees of redundancy (Table 2).

For the example module following the Statical Fatigue Curves section, for which  $p_I = 0.054$ , the degree of interconnect redundancy and associated 20-year array power reduction can now be determined for the example array field under consideration. Table 5 suggests three interconnects per parallel interconnect group, giving a minimum cost of delivered energy of 0.0385 \$/kWh. The array power loss fraction at 20 years (Table 2) is an acceptable 0.0088 (see example following equation (7)).

## **Thermal Cycling Testing**

Thermal cycling testing of modules is performed to qualify modules for field application. One test profile in common use is shown in Fig. 11; the most recent test specifications require N=200 test cycles [9]. For this test profile,  $\Delta T_{\rm test}=130^{\circ}{\rm C}$ . Then for a site for which  $\Delta T_{\rm field}=46^{\circ}{\rm C}$ ,

$$\Delta \epsilon_{\text{test}} = \frac{\Delta T_{\text{test}}}{\Delta T_{\text{field}}} \Delta \epsilon_{\text{field}} = 2.83 \Delta \epsilon_{\text{field}}$$
 (9)

To determine the maximum allowable number of interconnect failures in the test, use is made of the statistical fatigue curve, Fig. 7, reproduced in Fig. 12. An example in the figure shows that qualification for 20-year service at a 10 percent cumulative interconnect field-failure level requires that there be less than 3.5 percent failures at 200 test cycles. This type of calculation is continued to generate Fig. 13, which gives the maximum allowable interconnect test failure level for a specified number of test cycles to qualify a module for 20-year service at a typical field site for which  $\Delta T \approx 46^{\circ}\text{C}$ . The

Table 5 Life-cycle energy costs

Table of the cycle chargy costs								
Maximum allowable strain	Life-cycle energy cost R, \$/kWh							
	r=1	2	3	4	5	6		
0.0055	0.0415	0.0382	0.0383	0.0386	0.0391	0.0397		
0.0056	0.0445	0.0383	0.0384	0.0386	0.0391	0.0397		
0.0061	0.0632	0.0392	0.0385	0.0387	0.0391	0.0397		
0.0067	0.0960	0.0419	0.0388	0.0388	0.0391	0.0397		
0.0072	0.1680	0.0462	0.0392	0.0389	0.0391	0.0397		
0.0077	0.3285	0.0577	0.0415	0.0395	0.0393	0.0397		
0.0085	0.4284	0.0680	0.0448	0.0414	0.0397	0.0399		
0.0091	0.4620	0.0770	0.0505	0.0452	0.0418	0.0414		
0.0096	0.4928	0.0856	0.0581	0.0495	0.0449	0.0443		
	allowable strain 0.0055 0.0056 0.0061 0.0067 0.0072 0.0077 0.0085 0.0091	$\begin{array}{c} \text{Maximum} \\ \text{allowable} \\ \text{strain} \end{array} \qquad \begin{array}{c} r = 1 \\ \hline \\ 0.0055 \\ 0.0056 \\ 0.00415 \\ 0.0061 \\ 0.0632 \\ 0.0067 \\ 0.0960 \\ 0.0072 \\ 0.1680 \\ 0.0077 \\ 0.3285 \\ 0.0085 \\ 0.4284 \\ 0.0091 \\ 0.4620 \\ \end{array}$	$\begin{array}{c ccccccccccccccccccccccccccccccccccc$	$\begin{array}{c ccccccccccccccccccccccccccccccccccc$	$\begin{array}{c ccccccccccccccccccccccccccccccccccc$	$ \begin{array}{c ccccccccccccccccccccccccccccccccccc$		

Table 6 Module qualification thermal cycle test results: 20-year service at  $\Delta T \approx 46$  °C

Type of module	No. of thermal cycles $(\Delta T = 130^{\circ}\text{C})$	Observed Interconnect test failure level, %	Qualification field failure		Qualification for 5% field failure level	
			Max. allowable test failure level, %	Judgment	Max. allowable test failure level, %	Judgment
Randomly oriented glass fiber substrate	297 575 297 575 297	67 69 36 69 31	10.0 27.0 10.0 27.0 10.0	Failed Failed Failed Failed Failed	3.2 15.0 3.2 15.0 3.2	Failed Failed Failed Failed Failed
Superstrate	247	0	7.2	Passed	3.3	Passed
Superstrate	446	3	18.4	Passed	10.4	Passed
Superstrate	397	0	15.5	Passed	8.2	Passed
Substrate	547 547	6 10	25.0 25.0	Passed Passed	14.0 14.0	Passed Passed
Substrate	497 497	0 7	21.0 21.0	Passed Passed	12.0 12.0	Passed Passed

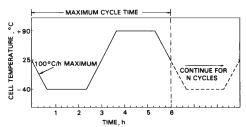


Fig. 11 Thermal-cycling test conditions

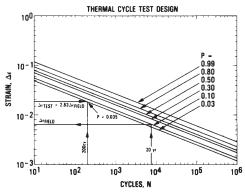


Fig. 12 Thermal cycle test design for module qualification at typical site ( $\Delta T \approx 46\,^{\circ}\text{C}$ )

example on the graph indicates that the test failures should not exceed 3.5 percent at 200 cycles to qualify a module for 20-year service at a 10 percent field-failure level.

Table 6 presents thermal cycling test data and results from several differently designed modules. Pass-fail judgments are based on the criteria established in Fig. 13. The field-failure level for which the module is being qualified is seen to be an important factor in making pass-fail judgments.

Finally, because the purpose of thermal cycling testing is to provide type approval of a particular module design, a number of modules from the same lot—enough to provide at least 300 interconnects—should be tested in order to present a believable statistical picture of interconnect failures for that design.

#### **Discussion**

Discussion of the test and design philosophy, and suggested directions for future research, follow:

- 1 This investigation focused on the thermally induced mechanical-fatigue failure of interconnects. The design and cost-optimization algorithms are predicated on the assumption that array power loss is attributable solely to interconnect failures, to the exclusion of such other contributing effects as cell breakage, encapsulation discoloration, electrical insulation failure, etc. A logical extension of this work is the incorporation of these and other factors into the design and cost algorithms.
- 2 Although the fatigue curves presented in this paper are limited to copper interconnects, the procedures developed are general. Another phase of this research involves the study of aluminum and clad metals. Aluminum exhibits fatigue behavior poorer than that of copper but is much less expensive. Clad metal interconnects, on the hand, although more expensive to manufacture, exhibit none of the fabrication problems associated with aluminum interconnects and in addition may offer improved resistance to fatigue failures [3].
  - 3 It is of interest to compare the statistical fatigue curves

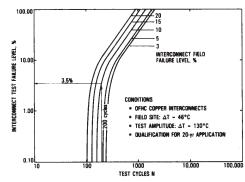


Fig. 13 Maximum allowable interconnect test failure levels for a specified number of test cycles with field failure level as parameter (qualification for 20-year service at  $\Delta T \approx 46\,^{\circ}\text{C}$ )

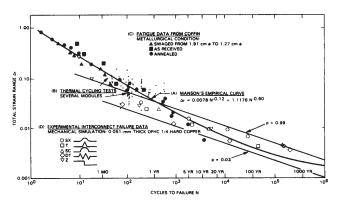


Fig. 14 Fatigue information: OFHC copper

presented here to the classical fatigue curve for OFHC copper given by an empirical formula suggested by Manson [10]:

$$\Delta \epsilon = 0.0078 \ N^{-0.12} + 1.1178 \ N^{-0.60}$$

The curve is plotted in (A) of Fig. 14. The unshaded data points (B) in Fig. 14 are the 50 percent failure points determined from the raw data of Fig. 6. They are enveloped by two straight lines, the 3 percent and 99 percent failure curves from the family of statistical fatigue curves generated in this research. In the range of interest to module designers (5-30 years) the agreement is good.

The shaded points (C) in Fig. 14 represent conventional mechanical fatigue data for OFHC copper in widely varying metallurgical conditions [11]. Manson's curve also agrees well with these data.

Thermal cycle test data are plotted in (D) of Fig. 14 as a cloud of points between N=47 cycles and N=575 cycles. Agreement with the Manson curve is good. The not-too-good agreement with the statistical fatigue curves leads to conservative prediction, i.e., underestimation, of interconnect life.

4 Elastic behavior on the part of the interconnect has been assumed in this study in using the finite-element modeling procedure to calculate interconnect strains. In reality, however, interconnect behavior is largely plastic. Two factors justify using elastic analysis to determine strain in interconnects behaving plastically in service. The first is cost; the cost of performing plastic analysis is prohibitive. The second is that elastic analysis yields good results (it works) as is evident from the data of Fig. 14. In that figure, the plotted experimental data points for which strain levels have been computed agree well with the empirical elastic-plastic fatigue curve of the interconnect material.

5 The large temperature range of the module thermal cycling test and the rapid cycling of interconnects in the mechanical simulation tests-both contrary to existing field conditions—may be questioned. Most investigators seem to disregard cycle rate and moderate temperature extremes as influential factors in the mechanical fatigue of metals. The various experimental data presented in Fig. 14 agree well with one another despite considerable variation in cycle rate. The mechanical simulation tests are conducted at 30 cycles per minute, the thermal cycling test at 4 cycles per day. The data of Coffin and Tavernelli [11] were obtained at 7-16 cycles per minute, and field cycles are 1 per day.

The fundamental requirement of an accelerated test is that it not introduce degradation modes not active in the intended application. Enhanced temperature range (thermal-cycling tests) or lack thereof (mechanical simulation test) were not observed to violate this requirement. In fact, many degradation modes are suppressed in such tests, e.g., hail impact, wind loading, etc., but these modes do not generally contribute substantially to interconnect failures. The major interconnect failure mechanism is thermally induced strain cycling [10], i.e., fatigue, and the primary cause of premature interconnect failure is faulty module-interconnect design.

## **Concluding Remarks**

Interconnect fatigue performance has been characterized by the interconnect material fatigue curve. Nomographs have been developed to facilitate the computation of interconnect strain. Based on the interconnect material fatigue curve and experimental failure rate data, array life prediction has been demonstrated. A design algorithm has been developed enabling the selection of minimum-cost redundant interconnect systems. Thermal cycling testing of modules for the purpose of characterizing interconnect performance has been given a quantitative foundation—particularly in regard to acceptance-or-rejection threshold levels.

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